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# Chemical exfoliation efficacy of semiconducting WS<sub>2</sub> and its use in an additively manufactured heterostructure graphene–WS<sub>2</sub>–graphene photodiode

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In the present work, various chemical exfoliation routes for semiconducting two-dimensional (2D) layered material WS<sub>2</sub> are explored, which include magnetic stirring (MS), shear mixing (SM), and horn-tip (HT) sonication. Current–voltage measurements, Raman spectroscopy, and photoluminescence (PL) spectroscopy were used to characterize the drop-casted WS<sub>2</sub> nanosheets produced by these three techniques and our analysis revealed that HT sonication produced the most optimal dispersions. Heterostructure photodetector devices were then fabricated using inkjet printing of the HT sonicated dispersions of WS<sub>2</sub> and graphene. The photodetector device performance was measured using a stream of ON/OFF light pulses generated using a red laser with wavelength  $\lambda \sim 660$  nm, and an arbitrary waveform generator. From this analysis, the photoresponsivity and detectivity of the graphene–WS<sub>2</sub>–graphene heterostructure devices were calculated to be  $\sim 0.86$  A W<sup>-1</sup> and  $\sim 10^{13}$  Jones, respectively. Capacitance–voltage (C–V) and C–frequency (*f*) measurements were also conducted, where the *V* was swept from –6 V to +6 V, while the change in *C* was measured from *f*  $\sim 20$  kHz up to 3 MHz to gain insights into the nature of the graphene–WS<sub>2</sub> interface. From the C–V measurements, the *C* plateaued at  $\sim 324.3$  pF from  $\sim -4$  V to +4 V for the lowest *f* of 20 kHz and it reduced to  $\sim 200$  pF from –6 V to  $\sim -4$  V, and similarly from  $\sim 4$  V to 6 V, *C* was  $\sim 190$  pF. The decrease in *C* for *V* > +4 V and *V* < –4 V was attributed to the reduction of the interfacial barrier at the electrodes which is suggestive of a Schottky-based photodiode at the graphene–WS<sub>2</sub> interface. A sharp decrease in *C* from  $\sim 315.75$  pF at 25.76 kHz to  $\sim 23.79$  pF at 480 kHz (at 0 V bias) from the C–*f* measurements suggests a strong effect of interface trap density on *C* built-up at the graphene–WS<sub>2</sub> interface and the ensuing Schottky barrier height. Our work confirms the excellent potential of solution-cast, trilayer graphene–WS<sub>2</sub>–graphene heterostructures as a promising photodetector platform using additively manufactured inkjet printing.

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## 1. Introduction

Since the first isolation of graphene in 2004,<sup>1,2</sup> various layered materials have been the subject of extensive research, specifically, the transition metal dichalcogenides (TMDCs) that have shown great interest amongst researchers due to their interesting electronic,<sup>3</sup> optical,<sup>4</sup> mechanical,<sup>5</sup> and chemical<sup>6</sup> properties. They represent a class of materials with the formula MX<sub>2</sub>, where M is a transition metal element (*e.g.* Mo, W, Ti, V, or Nb) and X is a chalcogen (S, Se or Te). The TMDCs have a layered structure in the form of X–M–X, where two planes of chalcogen

atoms are separated by a plane of the metal atoms.<sup>5</sup> In many of these semiconducting TMDCs, such as MoS<sub>2</sub> and WS<sub>2</sub>, an indirect-to-direct band gap transition is also observed when the bulk layered material is exfoliated to its monolayer form.<sup>7,8</sup> These TMDCs also possess sizeable band gaps of  $\sim 1$  to 2 eV which positions them well for many electronic and optoelectronic devices and makes them attractive as viable alternatives to Si-based (bandgap  $\sim 1.14$  eV) or GaAs-based (bandgap  $\sim 1.43$  eV) electronics and optoelectronics.<sup>9</sup>

While significant work has been conducted on the exfoliation studies of MoS<sub>2</sub> to better understand its optical and electronic properties,<sup>10–14</sup> the body of work on similar exfoliation studies on WS<sub>2</sub> is sparser. In its bulk state, WS<sub>2</sub> has an indirect bandgap of  $\sim 1.4$  eV but it morphs to a direct bandgap of  $\sim 2.1$  eV when thinned to its monolayer form,<sup>15</sup> which makes it attractive for high-performance optoelectronics<sup>16–19</sup> and photodetectors operational in the visible regime. Photodetectors are used in a wide range of

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applications from imaging to optical communication, as they convert light into electrical signals.<sup>20–24</sup> Conventional semiconductors such as Si and GaAs used in photodetectors are usually opaque and their brittle nature limits their use on rigid substrates only. The band gap in the visible part of the electromagnetic spectrum and the presence of Van Hove singularities in the electronic density of states enables WS<sub>2</sub> nanosheets to exhibit transparency while displaying strong light–matter interactions. They have also demonstrated high performance on flexible substrates with bending curvature down to 5 mm.<sup>25</sup> These remarkable properties empower WS<sub>2</sub> to overcome some of the limitations associated with conventional semiconducting channel materials (*e.g.* Si, GaAs) and promotes its use in bendable and transparent photodetector devices.<sup>26–28</sup>

The exfoliated WS<sub>2</sub> nanosheets for photodetection and other applications involving the use of a semiconducting channel are produced using bottom-up approaches comprising of physical vapor deposition (PVD)<sup>29</sup> or chemical vapor deposition (CVD),<sup>30</sup> where the WS<sub>2</sub> molecules assemble to form mesoscopic 2D nanosheets. The WS<sub>2</sub> nanosheets may also be produced using a top-down approach such as mechanical<sup>31</sup> or chemical exfoliation<sup>32</sup> where layers of WS<sub>2</sub> membranes are isolated from the bulk toward nanoscale dimensions. Moreover, liquid-phase or chemical exfoliation has been the subject of numerous studies, as it offers a range of advantages over other methods, which includes low-cost, low-temperature (as low as room temperature) processing, attractive scalability towards large formats and its material conserving nature.<sup>33,34</sup> In general, oxidation and subsequent dispersion in appropriate solvents, ion-intercalation, ion-exchange, and sonication-assisted exfoliation remain commonly explored methods for chemical exfoliation.<sup>35</sup> However, to date, there is no prior work that reports on comparing the efficacy of WS<sub>2</sub> chemical exfoliation routes operational at near room temperature.

In the present work, we have conducted an extensive analysis of several exfoliation routes for forming eco-friendly dispersions of WS<sub>2</sub>, which includes magnetic stirring (MS), shear mixing (SM), and horn-tip (HT) sonication. After determining the optimal exfoliation route, graphene–WS<sub>2</sub>–graphene heterostructure photodetectors were designed and fabricated, where WS<sub>2</sub> is used as the semiconducting channel material, and graphene, given its finite density of states at the *k*-point from Dirac cones of valence and conduction bands, chemical inertness, and high stability, is used as a highly conducting electrode material.<sup>36</sup> Inkjet printing has been employed as a material-conserving technique for the precise deposition of graphene and WS<sub>2</sub> nanosheets<sup>37,38</sup> in picoliter volumes, which enables ink flow (printable liquid) from the cartridge to the substrate. The liquid undergoes some drying after impact on the substrate depending on the platen temperature used. Raman and photoluminescence (PL) spectroscopy, photocurrent *I<sub>p</sub>*, capacitance–voltage (*C–V*), and *C–frequency* (*f*) measurements were amongst the techniques used to characterize our all inkjet-printed photodetector devices which are presented in this paper.

## 2. Results

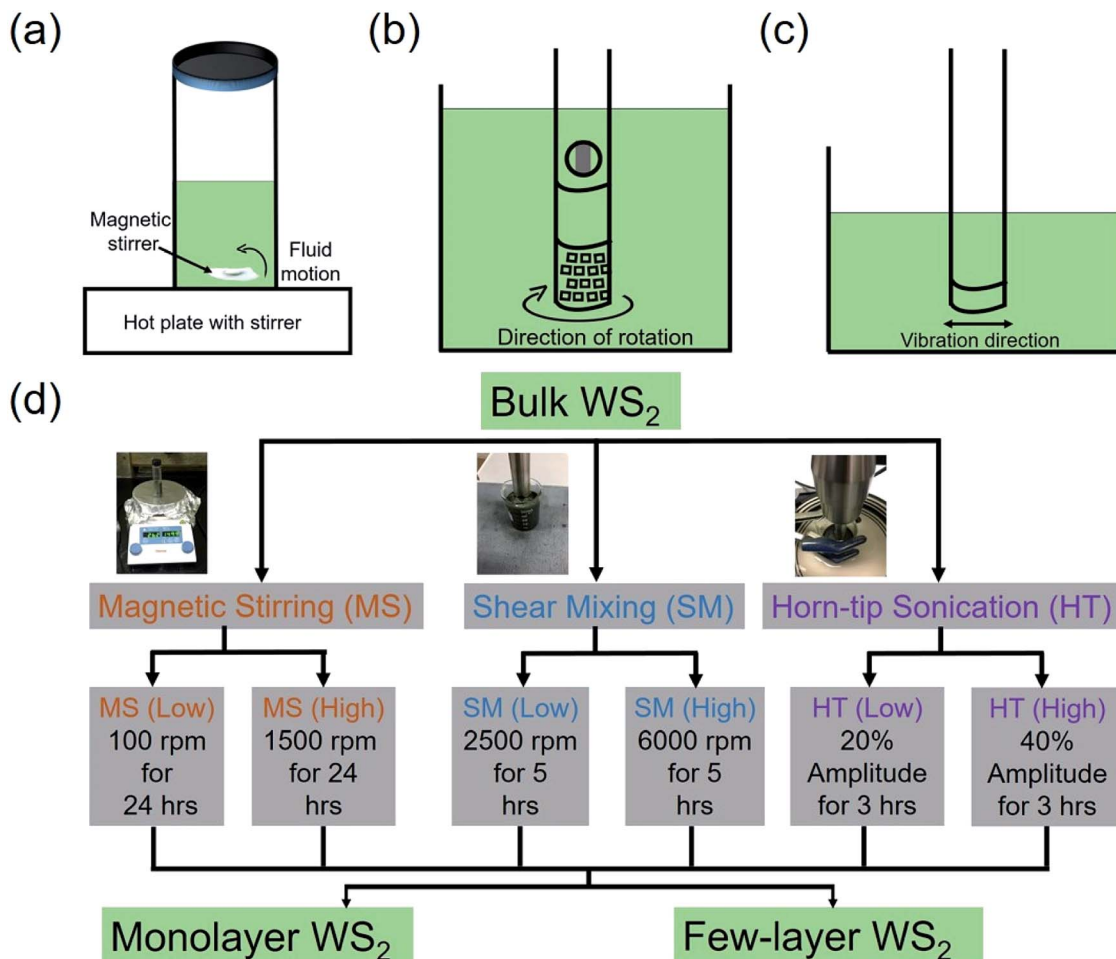
As noted, the three techniques used in this work to disperse WS<sub>2</sub> in chemical dispersions are magnetic stirring (MS), shear mixing (SM) and horn-tip (HT) sonication. These techniques are illustrated schematically in Fig. 1, which shows the various mechanisms and parameters used in producing single-to-few layer WS<sub>2</sub> nanosheets. The first technique, MS, uses a magnetic field to create fluidic shear forces that are generated as a bar magnet is spun in the liquid to generate the stirring and exfoliation action illustrated in Fig. 1(a). The magnetic stirrer moves the fluid in a clockwise direction at predefined revolutions per minute (rpm). When a vial containing the magnetic stirrer and the liquid are placed above the hot plate, the magnetic stirrer also starts to move in a clockwise direction at the same rpm. The energy provided by stirring breaks the 3D layered materials into 2D nanosheets. In the second technique, SM, exfoliation results when a shear force is produced such that one area/layer of the fluid travels with a different velocity relative to the adjacent area/layer. Fig. 1(b) demonstrates the mechanism of shear mixing used in the current work. High-speed rotation of the rotor blades in a clockwise direction results in the shearing of nanosheets that experience a velocity differential, causing the layers to peel apart. The third technique, exfoliation by HT sonication, exposes the layered material to ultrasonic waves in an appropriate solvent by inducing vibrations through a horn-tip; this is shown in Fig. 1(c). Ultrasonic waves generate cavitation bubbles that collapse into high energy jets, breaking up the layered crystallites to produce exfoliated nanosheets.

The parameters used for MS, SM, and HT sonication are summarized in Fig. 1(d). Here, MS (low) and MS (high) refer to magnetic stirring conditions of 100 rpm and 1500 rpm for 24 hours, respectively. The SM at 2500 rpm and 6000 rpm for 5 hours is referred to as SM (low) and SM (high), respectively, whereas the HT sonication at 20% and 40% power amplitude is denoted as HT (low) and HT (high), respectively.

The *I–V* response for drop-casted, annealed MS (low) and MS (high) samples are depicted in Fig. 2(a), while the *I–V* characteristic for drop-casted, annealed SM (low) and SM (high) samples are shown in Fig. 2(b). The inset in Fig. 2(a) shows current data on an expanded scale for the MS (low) case. Similarly, Fig. 2(c) displays the *I–V* behavior for drop-casted and annealed HT (low) and HT (high) samples. All drop-casted samples demonstrated non-ohmic behavior, as shown in Fig. 2(a)–(c), suggestive of the strong semiconducting nature of the WS<sub>2</sub> nanosheets. From the electronic transport data, it is evident that the higher electrical conductivity is obtained when WS<sub>2</sub> is exfoliated at a higher speed of MS (Fig. 2(a)), higher speed of SM (Fig. 2(b)), and at a higher amplitude of HT sonication (Fig. 2(c)), when the time is kept fixed; this suggests that when the net power applied to the solution is greater, a higher exfoliation rate occurs in all of the three exfoliation routes examined.

Raman and photoluminescence (PL) spectroscopy were used to characterize the ensuing material generated at the low- and





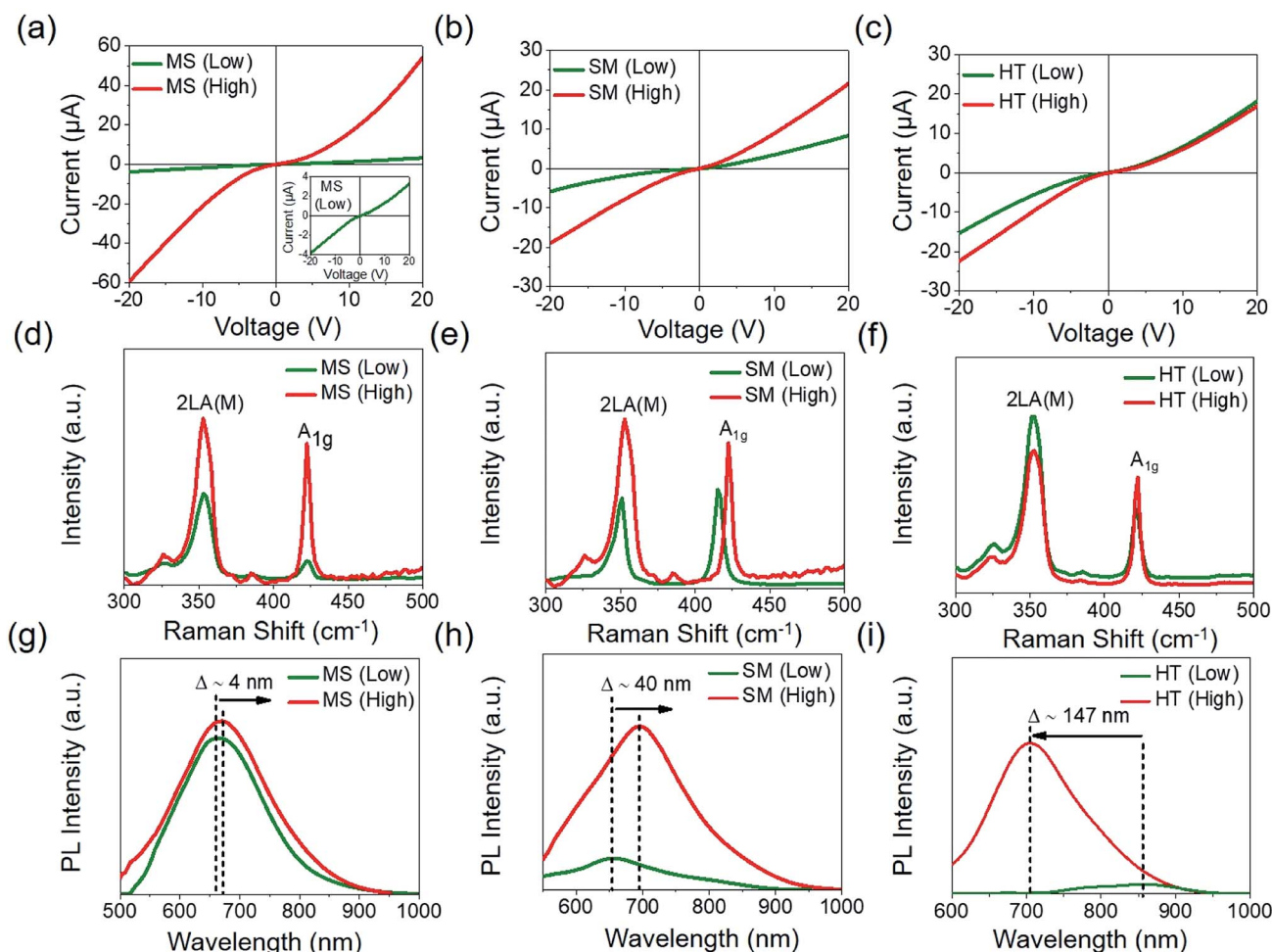
**Fig. 1** Mechanism of (a) magnetic stirring (MS), (b) shear mixing (SM), and (c) horn-tip sonication (HT). The MS exfoliation route utilizes a magnetic field to create fluidic shear forces that are generated as a bar magnet is spun in the liquid to exfoliate the material. The energy provided by stirring breaks the 3D layered materials into 2D nanosheets. The SM exfoliation route exploits the high-speed rotation of the rotor blades resulting in shearing nanosheets due to a velocity differential between them. The HT technique exposes the layered material to ultrasonic waves by inducing vibrations through a horn-tip. Ultrasonic waves generate cavitation bubbles that collapse into high energy jets, breaking up the layered crystallites to produce exfoliated nanosheets. (d) Schematic illustration of the various parameters used for the three techniques for  $WS_2$  ink preparation. The C/T/EC solution mixture of 5 ml, 50 ml, and 20 ml was used for MS, SM, and HT sonication, respectively. These were the minimum concentrations necessary to facilitate the exfoliation with each technique.

high-level conditions for all the three exfoliation routes. In Raman spectroscopy, the interaction of an incoming laser with the molecular vibrations of the material under examination causes the energy of the reflected photons to either increase or decrease. This shift in energy gives information about the unique vibrational modes that serve as fingerprints of the material.<sup>39–41</sup> In  $WS_2$ , there are two primary Raman active modes, the  $A_{1g}$  mode which arises from the out-of-plane vibrations involving only sulfur atoms and occurs at  $\sim 418.8\text{ cm}^{-1}$  and the  $2LA(M)$  mode at  $\sim 352.4\text{ cm}^{-1}$  due to the in-plane displacement of the tungsten and sulfur atoms. The number of layers may be estimated by either monitoring the red-shift in the  $A_{1g}$  mode which refers to the lattice relaxation phenomenon due to the removal of layers,<sup>42</sup> or by calculating the intensity ratio,  $I_{2LA(M)}/I_{A_{1g}}$ .<sup>43</sup> As the exfoliation efficacy improves, the number of layers should decrease as deduced from the intensity ratio calculation which is the technique we utilized here. When

$I_{2LA(M)}/I_{A_{1g}} > 2.2$  it is suggestive of monolayers,  $I_{2LA(M)}/I_{A_{1g}} < 0.47$  signifies  $WS_2$  in its bulk form, and  $0.47 < I_{2LA(M)}/I_{A_{1g}} < 2.2$  occurs for few-layer  $WS_2$ . Fig. 2(d) shows the Raman spectra of MS (low) and MS (high) samples. The  $I_{2LA(M)}/I_{A_{1g}}$  [MS (low)] and  $I_{2LA(M)}/I_{A_{1g}}$  [MS (high)] were calculated to be  $\sim 3.83$  and  $1.17$ , respectively, indicating the presence of monolayer  $WS_2$  and few-layer  $WS_2$ . Similarly, Fig. 2(e) displays the Raman spectra of SM (low) and SM (high) samples. The  $I_{2LA(M)}/I_{A_{1g}}$  [SM (low)] and  $I_{2LA(M)}/I_{A_{1g}}$  [SM (high)] samples were found to be  $\sim 1.16$  and  $0.92$ , respectively, again indicating the presence of few-layer  $WS_2$ . Finally, Fig. 2(f) shows the Raman spectra of HT (low) and HT (high) samples. The  $I_{2LA(M)}/I_{A_{1g}}$  [HT (low)] and  $I_{2LA(M)}/I_{A_{1g}}$  [HT (high)] were determined to be  $2.11$  and  $1.23$ , respectively, again indicating the presence of few-layer  $WS_2$ . The  $I_{2LA(M)}/I_{A_{1g}}$  ratio of all the samples is summarized in Table 1.

Photoluminescence refers to the emission of light from a material after the absorption of photons. An extremely weak





**Fig. 2**  $I$ - $V$  measurements of drop-casted and annealed (a) MS (low) and MS (high) samples; inset shows the data for drop-casted and annealed MS (low) sample only on a magnified current scale.  $I$ - $V$  Characteristic for (b) SM (low) and SM (high) samples, and (c) HT (low) and HT (high) samples. Magnetic stirring showed the highest value of electrical conductivity followed by HT sonication and SM but the dispersions generated using MS were unstable. Raman spectra of drop-casted and annealed (d) MS (low) and MS (high) samples, (e) SM (low) and SM (high) samples, (f) HT (low) and HT (high) samples. Intensity ratios [ $I_{2LA(M)}/I_{A1g}$ ] of MS (low) and MS (high) sample were found to be 3.83 and 1.17, respectively, indicating the presence of few-layer  $WS_2$ . Intensity ratios of SM (low) and SM (high) samples were found to be 1.16 and 0.92, respectively, again indicating the presence of few-layer  $WS_2$ . Intensity ratios of HT (low) and HT (high) samples were found to be 2.11 and 1.23, respectively, again indicating the presence of few-layer  $WS_2$ . The intensity ratio values are summarized in Table 1. Photoluminescence spectra of (g) MS (low) and MS (high) samples, (h) SM (low) and SM (high) samples, and (i) HT (low) and HT (high) samples. Horn-tip sonication showed the highest blue-shift in the PL peak location from low-to-high conditions, where  $\Delta \sim 147$  nm was tabulated, while  $\Delta$  for SM was  $\sim 40$  nm (red-shifted) and  $\Delta$  for MS was  $\sim 4$  nm (red-shifted).

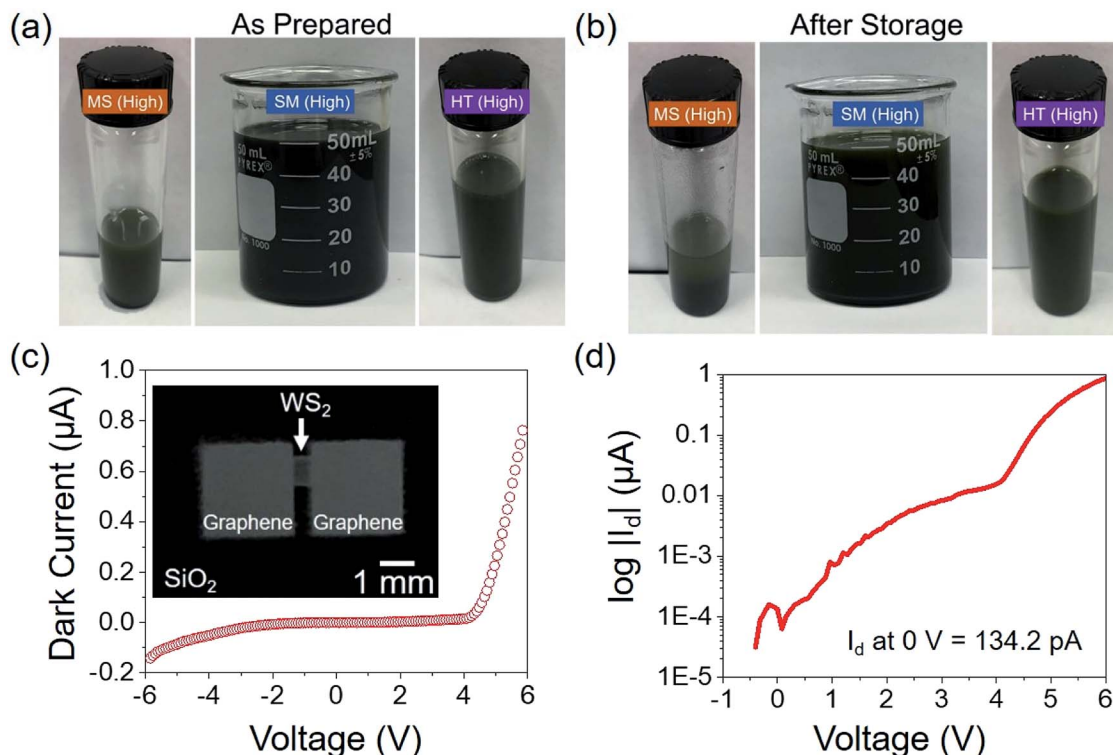
PL intensity is an indication of optical transitions that are poor and commonly associated with the indirect band-gap transitions in bulk 2D semiconducting samples.<sup>44</sup> The intensity of the PL spectra increases with a reduction in the number of atomic layers, suggesting direct interband transitions, and reaches a maximum when monolayers are formed. Full-width-at-half-maximum (FWHM) and PL peak shift  $\Delta$ , were calculated in order to study and compare PL behavior for the low- and high-

conditions for each of the three exfoliation routes. Fig. 2(g) shows the PL spectra of the MS (low) and MS (high) samples, where a single peak is evident. However, the PL peak of the MS (high) sample is broader with FWHM  $\sim 90.4$  nm and is red-shifted with  $\Delta \sim 4$  nm compared to the PL peak of the MS (low) sample which exhibited a FWHM  $\sim 87.2$  nm. Fig. 2(h) shows the PL spectra of the SM (low) and SM (high) samples displaying a single peak, but the FWHM was higher  $\sim 144.4$  nm

**Table 1** Comparison of intensity ratio ( $I_{2LA(M)}/I_{A1g}$ ) for samples prepared by different exfoliation routes

	MS (low)	MS (high)	SM (low)	SM (high)	HT (low)	HT (high)
$I_{2LA(M)}/I_{A1g}$	3.83	1.17	1.16	0.92	2.11	1.23





**Fig. 3** Optical images of MS (high)-left, SM (high)-middle, and HT (high)-right samples for (a) as prepared, and (b) after 12 hours of storage. The MS (high) sample showed precipitation of  $\text{WS}_2$  nanosheets after 12 hours due to the greyer solution dispersion in (b)-left, whereas the SM (high)-middle and HT (high)-right samples showed no visible precipitation given the darker colored dispersions persistent after storage. (c) The dark current  $I_d$ - $V$  measurement of inkjet printed graphene- $\text{WS}_2$ -graphene heterostructure device where the inset depicts the inkjet printed graphene- $\text{WS}_2$ -graphene heterostructure sample. (d) Dark current  $I_d$ - $V$  measurement on a log-scale which shows that  $I_d \sim 134.2 \text{ pA}$  at 0 V which was the value used for the responsivity and detectivity calculations.

for the SM (high) sample, and the red-shift  $\Delta$  was  $\sim 40 \text{ nm}$  compared to the SM (low) sample with FWHM  $\sim 43.6 \text{ nm}$ . Fig. 2(i) shows the PL spectra of the HT (low) and HT (high) samples. The PL spectra of the HT (high) sample showed a strong single peak with FWHM  $\sim 142.6 \text{ nm}$  and  $\Delta$  is blue-shifted significantly approaching  $\sim 147 \text{ nm}$  from the weakly defined PL peak of HT (low) sample. It's interesting to note that the HT sonicated samples were the only ones where the PL peak was blue-shifted at the higher conditions, while the MS and SM samples exhibited red-shifts in the PL peaks. The higher PL intensity of MS (high), SM (high), and HT (high) relative to the MS (low), SM (low), and HT (low), respectively, suggests a greater degree of exfoliation toward thinner molecular membranes.

The higher electrical conductivity of the MS (high), SM (high), and HT (high) samples may be due to the lower resistance offered by the few-layer  $\text{WS}_2$  nanosheets since inter-layer transport amongst the van der Waals solids is typically poor.<sup>45,46</sup> However, MS (low) and MS (high) samples appeared to be unstable and  $\text{WS}_2$  nanosheets precipitated to the bottom of the vial in less than 12 hours. On the other hand, SM (low), SM (high), HT (low) and HT (high) samples were stable for at least 1 month, indicating the practical utility of such inks for prototype device platforms with ink jet printing. The images of the as-prepared solutions and after 12 hours of storage are shown in

Fig. 3(a) and (b), respectively. These images illustrate the slightly greyer solution in (b) for the MS (high) case after 12 hours of storage compared to the starkly black dispersion in the as-prepared case in the left-most vial of Fig. 3(a), which suggests that precipitation is occurring after storage for the MS dispersions. In contrast, no visual precipitation or color changes were observed for the SM and HT samples implying their greater stability, to first order. However, HT (high) samples showed higher electrical conductivity among the four stable dispersions, and coupled with the fact that HT sonication resulted in a significant blue-shift of the PL peak, suggestive of quantum confinement effects arising from thinner membranes. It is interesting to note that sonication indeed reduces membrane size of our 2D semiconducting materials as based on our prior studies on  $\text{WS}_2$ . Here the mean size for the as received  $\text{WS}_2$  powder was  $\sim 18 \mu\text{m}$  which was reduced to above  $2 \mu\text{m}$  after sonicating for 30 min. Interestingly, mean particle size for the first mode remained largely unchanged with sonication times of up to 18 hours.<sup>47</sup> Additionally, the thickness of the printed patterns/films can be controlled with the number of printing passes. As an example, we have reported the change in thickness of graphene patterns that were formed using similar procedures, where the thickness changed from  $\sim 505 \text{ nm}$  for 10 printing passes to  $\sim 1667 \text{ nm}$  for 50 printing passes in our recent prior work.<sup>48</sup> Given that HT sonication resulted in



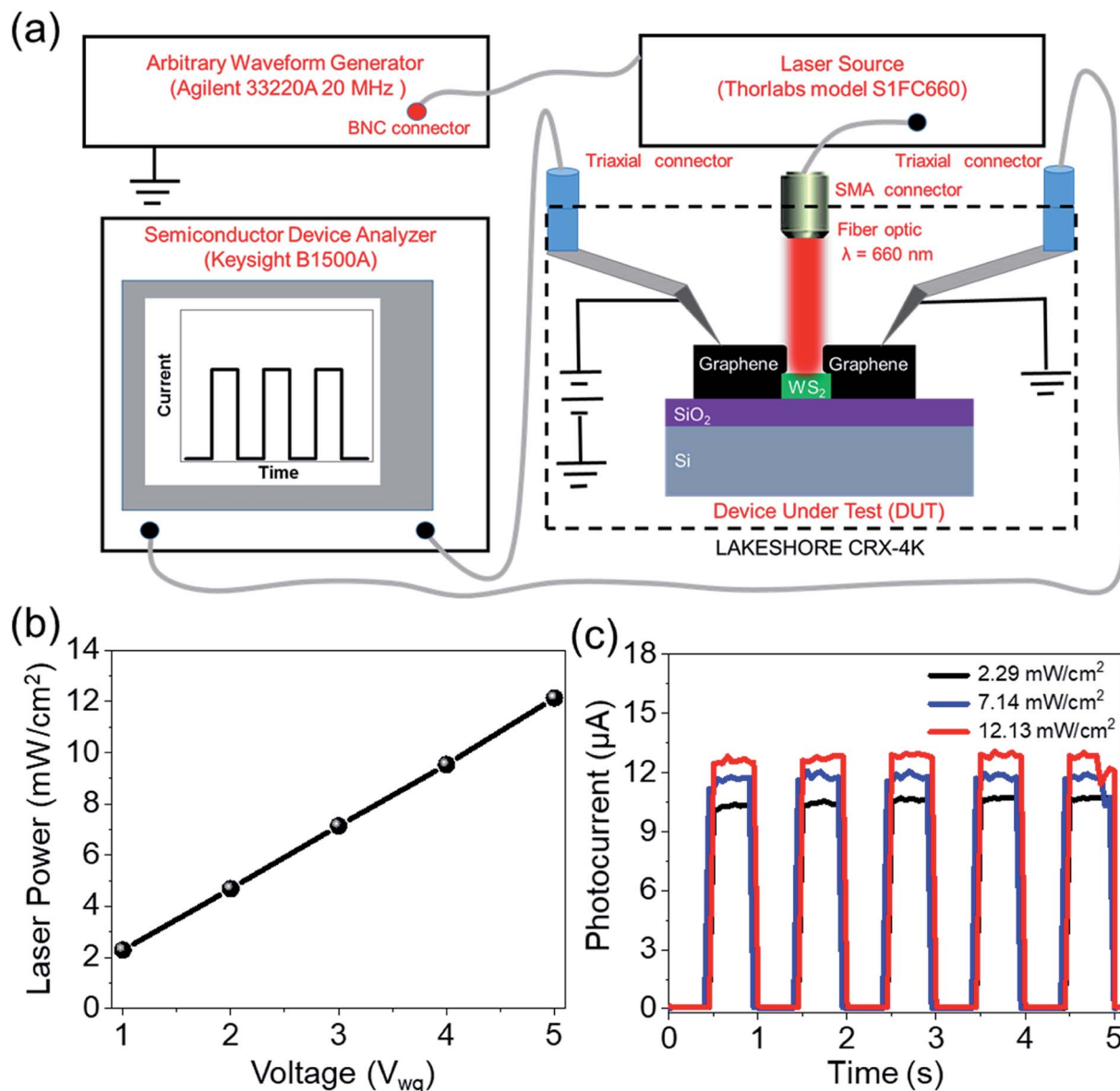


Fig. 4 (a) Photodetection measurement set-up comprising of an arbitrary waveform generator as a source of pulses to provide input to the laser source, which lases at  $\lambda \sim 660$  nm and was used to irradiate the DUT placed in the probe station. The semiconductor device analyzer is used to measure the photocurrent output. (b) Variation of laser power  $P_{\text{laser}}$  with the input voltage  $V_{\text{wg}}$ . The magnitude of the  $P_{\text{laser}}$  is altered by changing the  $V_{\text{wg}}$ . Higher  $V_{\text{wg}}$  leads to higher  $P_{\text{laser}}$  generation. (c) Variation in photoresponse of the inkjet printed graphene- $\text{WS}_2$ -graphene heterostructure device for three levels of  $P_{\text{laser}}$  used. The  $P_{\text{laser}}$  is directly proportional to photocurrent generation, where the higher  $P_{\text{laser}}$  generates a larger number of charge carriers which leads to a higher photocurrent.

thinner membranes based on the Raman and PL data, it was used as the approach of choice for inkjet printing our photodetector devices which we report on next.

Horn-tip sonication was used at a 40% power amplitude for 3 hours to form the graphene and  $\text{WS}_2$  inks. The line pattern of 1 mm (width) and 0.8 mm (length) were printed using the  $\text{WS}_2$  inks at 40 passes followed by annealing at 250 °C for 2 hours. Two 3 mm  $\times$  3 mm graphene pads were then printed overlapping regions of the  $\text{WS}_2$  at the edges, such that the effective  $\text{WS}_2$  channel length was 0.6 mm, and the samples were then again annealed at 250 °C for 2 hours. The inset in Fig. 3(c) shows a representative image of the inkjet printed graphene- $\text{WS}_2$ -

graphene trilayer heterostructure device. Fig. 3(c) illustrates the dark current  $I_d$ - $V$  characteristic. The same  $I_d$ - $V$  graph is also plotted on a log scale, as depicted in Fig. 3(d), where  $I_d$  was measured to be  $\sim 134.2$  pA at 0 V; this value is used in our subsequent calculations for determining the device's electrical response to incident light or responsivity  $R$ , and the photodetector's sensitivity to incident light or detectivity  $D$ . The non-ohmic variation of dark current with voltage is an indication of the rectifying metal-semiconductor junction formation at the graphene- $\text{WS}_2$  interface, akin to a Schottky diode.

We then proceeded to make photodetector device measurements for which the measurement set up is displayed in



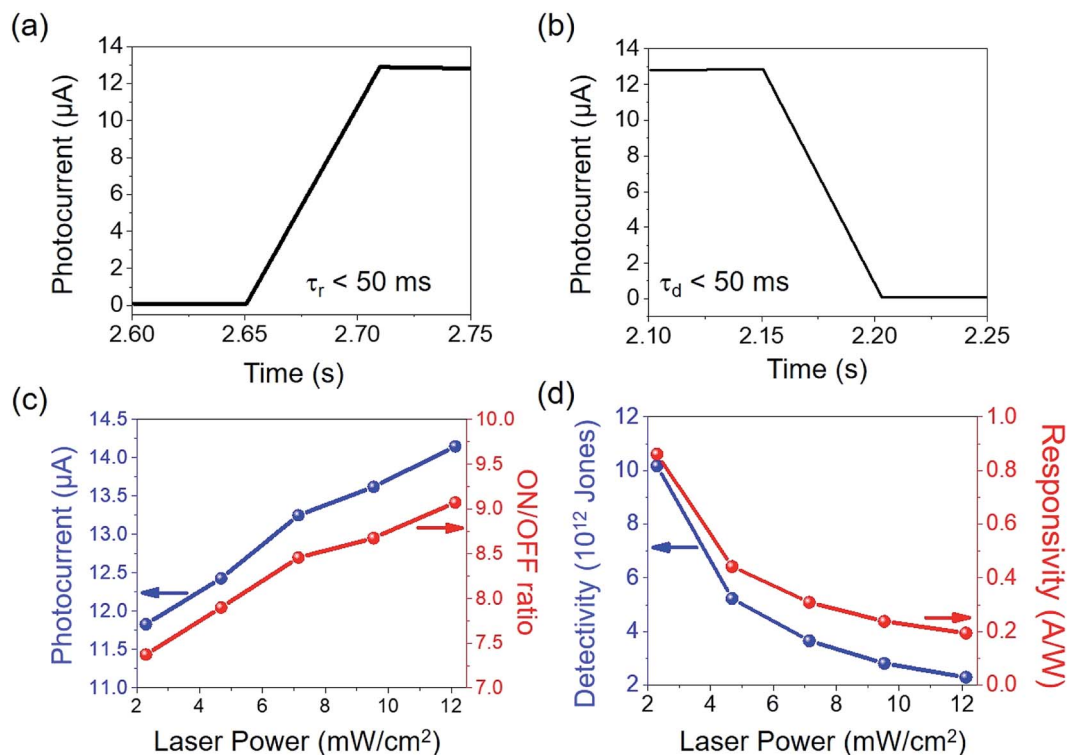


Fig. 5 Photocurrent-time graphs at laser power  $P_{\text{laser}}$  of  $\sim 12.13$  mW cm<sup>-2</sup> to show (a) rise time  $\tau_r$  and (b) decay time  $\tau_d$ . The average  $\tau_r$  and  $\tau_d$  were less than 50 ms for the inkjet printed graphene-WS<sub>2</sub>-graphene heterostructure device. (c) Variation of photocurrent  $I_p$ , and ON/OFF ratio with applied laser power  $P_{\text{laser}}$ . Photocurrent and ON/OFF ratio increased with an increase in input voltage or applied laser power due to the higher flow of charge carriers. (d) Detectivity  $D$ , and responsivity  $R$ , as a function of laser power  $P_{\text{laser}}$ . The  $D$  and  $R$  decrease inversely with  $P_{\text{laser}}$ , consistent with eqn (1) and (2).

Fig. 4(a), where an Agilent 33220A 20 MHz arbitrary waveform generator is used as the source of pulses to drive a ThorLabs laser source to produce a stream of periodic ON/OFF light pulses. The ThorLabs S1FC660 laser light source is used which lases at a wavelength  $\lambda \sim 660$  nm through the process of optical amplification. The laser light irradiates the device under test (DUT) mounted inside the Lakeshore CRX-4K cryogenic vacuum probe station. When the laser interacts with the semi-conducting WS<sub>2</sub> channel, enhanced electrical conductivity is obtained due to additional charge carriers generated by photon absorption. Laser ON and OFF cycles were generated and the current-time response of the device was captured using the Keysight B1500A semiconductor device analyzer, equipped with the medium power SMU B1511B module. The laser power  $P_{\text{laser}}$ , was varied by changing the input voltage from 1 V to 5 V in the waveform generator, referred to as  $V_{\text{wg}}$  which enabled  $P_{\text{laser}}$  to vary from 2.29 mW cm<sup>-2</sup> to 12.13 mW cm<sup>-2</sup>. A linear relation was observed between  $P_{\text{laser}}$  and the  $V_{\text{wg}}$  which is reproduced in Fig. 4(b). Fig. 4(c) illustrates the time-dependent photoresponse of the inkjet printed graphene-WS<sub>2</sub>-graphene heterostructure device, where the photocurrent  $I_p$  increases with  $P_{\text{laser}}$ , as  $P_{\text{laser}}$  rose from 2.29 mW cm<sup>-2</sup> to 12.13 mW cm<sup>-2</sup>.

The magnitude of  $I_p$ ,  $\tau_r$ ,  $\tau_d$ , ON/OFF ratio,  $R$ , and  $D$  are key figures-of-merit for characterizing the performance of photodetectors. The time required by the photodetector to reach 90% of maximum  $I_p$  value when the laser is switched ON is referred

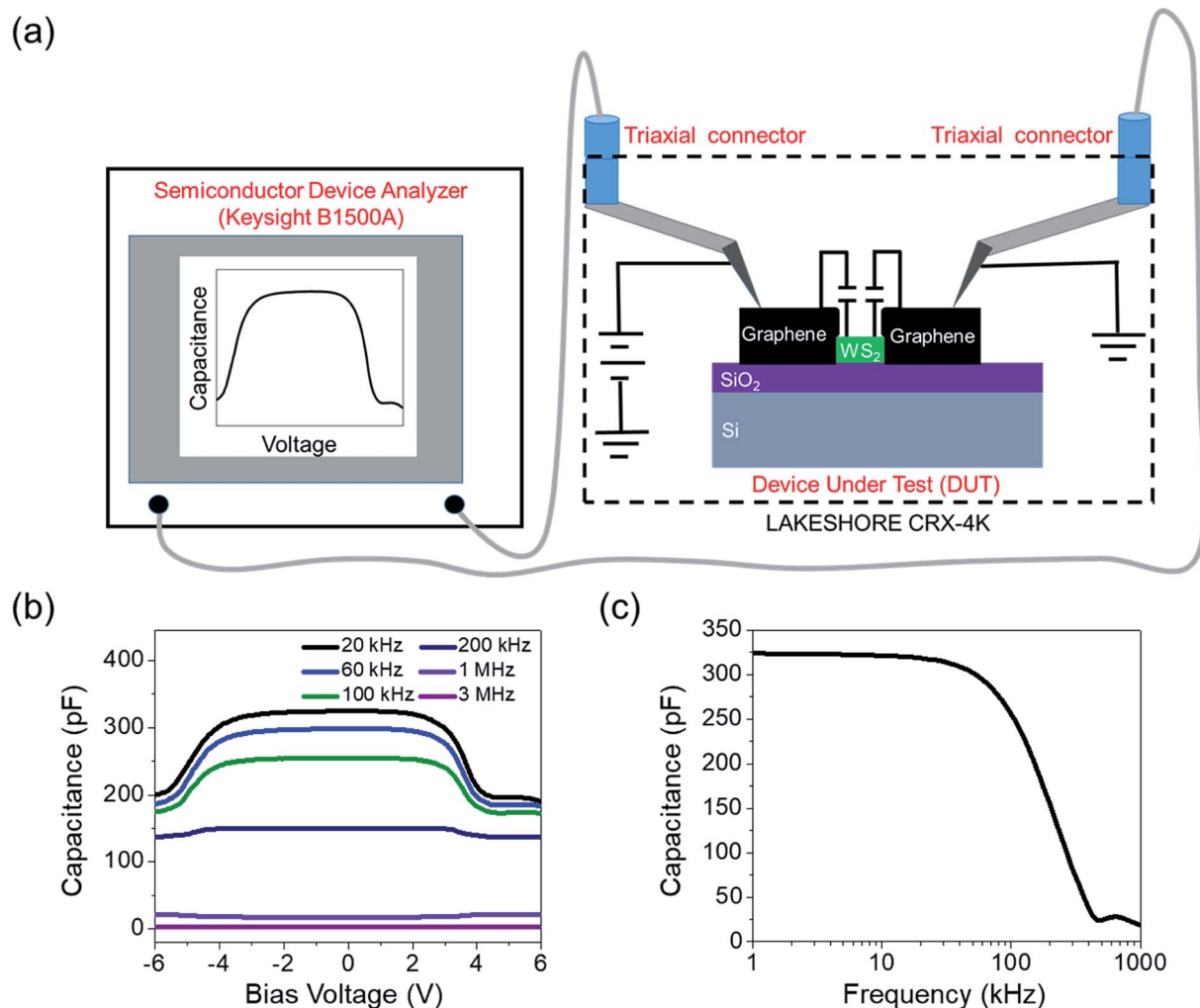
as the rise time and is denoted by  $\tau_r$ , whereas the time required by the photodetector to reach 10% of the maximum  $I_p$  value when the laser is switched off from its ON state is referred to as decay time and is denoted by  $\tau_d$ . The ON/OFF ratio refers to the ratio of the ON-state current and OFF-state current in a photodetector. The  $R$  and  $D$  are calculated by using eqn (1) and (2),<sup>49</sup> respectively, where  $A$  is the effective channel area in cm<sup>2</sup> and  $e$  is the electron charge ( $1.6 \times 10^{-19}$  C),

$$R = \frac{I_p - I_d}{P_{\text{laser}}} \quad (1)$$

$$D = \sqrt{\frac{A}{2eI_d}} R \quad (2)$$

In reviewing the prior work on WS<sub>2</sub>, Zhang *et al.*<sup>50</sup> synthesized WS<sub>2</sub> nanotubes by the high-temperature reaction of H<sub>2</sub> and H<sub>2</sub>S while also placing tungsten oxide nanoparticles in a large fluidized bed reactor. They reported Ti/Au/WS<sub>2</sub>(-nanotube) photodetectors with the  $\tau_r < 0.245$  ms,  $\tau_d < 0.358$  ms, ON/OFF ratio up to  $\sim 316$ , and  $R$  up to  $\sim 3.14$  A W<sup>-1</sup>. In another study, Huo *et al.*<sup>51</sup> reported Au/WS<sub>2</sub> based photodetector with  $\tau_r$  and  $\tau_d < 20$  ms and  $R \sim 5.7$  A W<sup>-1</sup>. Tan *et al.*<sup>45</sup> fabricated graphene-WS<sub>2</sub> based photodetectors synthesized by chemical vapor deposition where they obtained  $R$  up to 3.5 A W<sup>-1</sup> and  $D \sim 9.9 \times 10^{10}$  Jones. However, there is no reported prior work on





**Fig. 6** (a) Capacitance–voltage–frequency ( $C$ – $V$ – $f$ ) measurement setup to study the graphene– $\text{WS}_2$  and  $\text{WS}_2$ –graphene interface characteristics. The inkjet-printed graphene– $\text{WS}_2$ –graphene heterostructure device enacts the behavior of two Schottky diodes in series with each other. The graphene– $\text{WS}_2$  junction showed a non-ohmic rectifying behavior suggestive of its Schottky diode type behavior. (b) Capacitance at various frequencies as a function of bias voltage. The  $C$ – $V$  measurements exploit the formation of the depletion region and charging and discharging of capacitance formed within the junction. (c) Capacitance–frequency measurement demonstrating the strong dependence of capacitance with frequency. The decrease in capacitance with frequency is accredited to reduction or annihilation of interface trapped states.

graphene– $\text{WS}_2$ -based all inkjet-printed photodetector thus far, and our work is the first such report to develop and characterize such prototype devices based on inkjet printed  $\text{WS}_2$ .

Fig. 5(a) and (b) show the  $\tau_r$  and  $\tau_d$  of  $<50$  ms for a single pulse when  $P_{\text{laser}} \sim 12.13 \text{ mW cm}^{-2}$  was used in the current-time measurements. Fig. 5(c) shows the variation of  $I_p$  and ON/OFF ratio with increasing  $P_{\text{laser}}$ . The increase in  $I_p$  from  $\sim 11.83 \mu\text{A}$  to  $\sim 14.15 \mu\text{A}$  and subsequent increase in ON/OFF ratio from  $\sim 7.37$  to  $\sim 9.07$  with increase in  $P_{\text{laser}}$  from  $\sim 2.29 \text{ mW cm}^{-2}$  to  $\sim 12.13 \text{ mW cm}^{-2}$  is attributed to the generation of carriers through photon absorption that have energy higher than the band gap of  $\text{WS}_2$ , which leads to the generation of a higher number of electron–hole pairs since the flux of incoming photons increases as  $P_{\text{laser}}$  is increased. The variation of  $R$  and  $D$  with  $P_{\text{laser}}$  is shown in Fig. 5(d). In order to calculate  $R$  and  $D$ , the effective semiconducting channel area  $A$  of  $\sim 0.006 \text{ cm}^2$  (0.06 cm length by 0.1 cm width) was used for each value  $I_d$  and  $P_{\text{laser}}$ . The

inkjet printed graphene– $\text{WS}_2$ –graphene heterostructure device showed a high  $R$  of  $\sim 0.86 \text{ A/W}$  at a  $P_{\text{laser}} = 2.29 \text{ mW cm}^{-2}$ , while the maximum  $D$  obtained was  $\sim 10^{13}$  Jones at the same laser intensity.

Capacitance–voltage ( $C$ – $V$ ) measurements were also conducted to study the nature of the graphene (M)– $\text{WS}_2$  (S) interface. The voltage applied was across two graphene contacts by placing probe tips on these pads, as illustrated in Fig. 6(a). The  $C$  was measured as a function of bias voltage  $V$  using the Keysight B1500A semiconductor device analyzer with the multi-frequency CMU B1520A unit attached. As stated previously, the non-linearity in the  $I_d$ – $V$  measurement is attributed to the Schottky diode-type behavior of the graphene– $\text{WS}_2$  interfacial junction. Therefore, two Schottky diodes are in series with each other in the inkjet printed graphene– $\text{WS}_2$ –graphene heterostructure device. Fig. 6(b) shows the rise and fall in  $C$  at various frequencies ranging from 20 kHz up to 3 MHz, while  $V$  was





swept from  $-6$  V to  $6$  V. The initial rise in  $C$  with  $V$  is attributed to the formation of a Schottky barrier against electron flow at the graphene- $\text{WS}_2$  interface. Capacitance remains constant up to a certain bias voltage and then it decreases. The subsequent fall in  $C$  is attributed to the removal or reduction of the Schottky barrier at the  $\text{WS}_2$ -graphene interface, where the magnitude of  $C$  is dependent on the filling and refilling of trap states by the charge carriers.<sup>52,53</sup> Highest  $C$  values were measured at  $20$  kHz and at  $0$  V, where a value of  $\sim 324.88$  pF was tabulated, while the lowest  $C$  of  $\sim 2.81$  pF was measured at the highest  $f$  of  $\sim 3$  MHz and  $0$  V. The  $C$ - $V$  measurements help in deciphering the depletion region and in predicting the charging and discharging of capacitance<sup>54,55</sup>

From the data in Fig. 6(c), when the frequency  $f$  applied is significantly low, a higher value of  $C$  is observed because of the extra capacitance offered by interface trapped states. The fall in  $C$  with increasing  $f$  ( $>100$  kHz) is due to a decrease in the Schottky barrier height. No significant change in  $C$  was observed for  $f > 200$  kHz, indicating the absence of a barrier against electron flow. Thus, the  $C$ - $f$  measurements in Fig. 6(c) show the sharp decrease in capacitance from  $\sim 315.75$  pF at  $25.76$  kHz to  $\sim 23.79$  pF at  $480$  kHz frequency, indicating a strong frequency effect on capacitance built-up at the graphene- $\text{WS}_2$  interface. The decrease in  $C$  with increasing  $f$  is attributed to the fact that a fewer number of electrons are trapped in the interface states, owing to a decrease in the Schottky barrier height and after a certain  $f$ , their contribution toward the  $C$  formation is almost negligible. These results suggest that inkjet printed 2D semiconducting  $\text{WS}_2$  and conducting graphene layered materials formed using HT sonication show promise for the design of devices and components in RF and microwave engineering for future applications.

### 3. Conclusions

In summary, our work has revealed that HT sonication offered electrical conductivities higher than obtained by SM but lower than those obtained by MS, while providing the highest stability when compared to the other two techniques for formulating dispersions of semiconducting  $\text{WS}_2$ . From this work, the inkjet printed graphene- $\text{WS}_2$ -graphene heterostructure devices were constructed using HT sonication. The non-ohmic  $I$ - $V$  for the inkjet printed graphene- $\text{WS}_2$ -graphene heterostructure device indicated a Schottky diode type behavior where the optoelectronic properties were promising and yielded a maximum  $R$  of  $\sim 0.86$  A  $\text{W}^{-1}$ ,  $D \sim 10^{13}$  Jones, while  $\tau_r$  and  $\tau_d$  were  $<50$  ms. The  $C$ - $V$  measurements at various frequencies showed the rise and fall in capacitance values which is attributed to the formation and depletion of the Schottky barrier at the graphene- $\text{WS}_2$  and  $\text{WS}_2$ -graphene interfaces, respectively. The  $C$  obtained was as high as  $\sim 324.88$  pF at frequencies of  $\sim 20$  kHz, while it decreased down to  $\sim 2.81$  pF for frequencies as high as  $3$  MHz.

### 4. Experimental

Cyclohexanone (70%) (Sigma Aldrich # 398241)/terpineol (30%) (Sigma Aldrich # 86480) solution (C/T) mixtures were prepared

in glass vials. Ethyl cellulose, EC (2.5 weight%) (Sigma Aldrich # 200646) was then added to the solution and bath sonicated for 2 hours to ensure complete dissolution of EC in the C/T solution mixture. This particular combination of C/T/EC was used because it has a viscosity of about  $\sim 12$  cP which is ideal for inkjet printing, as reported in our previous work.<sup>56,57</sup> The  $\text{WS}_2$  powder (Sigma Aldrich # 243639) was used at a concentration of  $30$  mg  $\text{ml}^{-1}$  for all our experiments.

For MS, the  $\text{WS}_2$  powder was taken in two separate glass vials and  $5$  ml of C/T/EC solution mixture was then added to each vial. A magnetic stir bar was then put in both glass vials. One vial was magnetically stirred at  $100$  rpm (MS (low)), while another vial was stirred at  $1500$  rpm (MS (high)) for 24 hours to generate the dispersion.

For SM, the  $\text{WS}_2$  powder was taken in two separate glass beakers and  $50$  ml of C/T/EC solution mixture was then added as previously. This was the minimum amount of solution required for using our shear mixer. Lowest speed of  $2500$  rpm (SM (low)) and the highest speed of  $6000$  rpm (SM (high)) was used for 5 hours of shear mixing. These parameters were established to achieve uniform mixing while minimizing overheating.

For HT sonication, the  $\text{WS}_2$  powder was taken in two separate glass beakers and  $20$  ml of C/T/EC solution mixture was again added. This was the minimum amount of solution required for horn-tip sonication. A minimum power amplitude of 20% (HT (low)) and a maximum of 40% (HT (high)) was used for 3 hours. Pulse ON and OFF times were 30 seconds each, respectively, and the total sonication time was 6 hours. The parameters for sonication was also chosen such that it was performed at room temperature without overheating the samples.

Extreme parameters are used for all three methods with liquid-phase exfoliation to optimize the conditions for yielding semiconducting  $\text{WS}_2$  nanosheets that are stable for at least one month. One drop of each sample was cast on a  $\text{SiO}_2/\text{Si}$  wafer using a plastic pipette. Annealing was performed at  $250$  °C for 2 hours to ensure complete desorption of the solvent. The Fuji-film DMP-2800 series Dimatix Material Printer consisting of 16 inkjet nozzles were used to print graphene- $\text{WS}_2$ -graphene heterostructure devices discussed in this work. A cartridge temperature of  $\sim 40$  °C and a platen temperature of  $60$  °C were used for printing. Raman spectroscopy was performed using a Horiba LabRAM HR Evolution Microscope. Electrical characterization was performed using a micromanipulator 450PM-B probe stage equipped with an Agilent 4156A precision semiconductor parameter analyzer. The Lakeshore CRX-4K, Agilent 33220A 20 MHz arbitrary waveform generator, Thorlabs laser source model S1FC660 and Keysight B1500 semiconductor device analyzer with attached Keysight medium power SMU B1511B unit, were used for the  $I_d$ - $V$  and  $I_p$  measurements. The Lakeshore CRX-4K and Keysight B1500 semiconductor device analyzer with attached Keysight multi-frequency CMU B1520A unit were used for the  $C$ - $V$ - $f$  measurements of the graphene- $\text{WS}_2$ -graphene devices.



## Conflicts of interest

There are no conflicts to declare.

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